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PPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
09/899,383	07/03/2001	Scott A. Chalmers	02578.0006.CPUS01	3031
22930 75	590 09/04/2003			
HOWREY SIMON ARNOLD & WHITE LLP			EXAMINER	
BOX 34 1299 PENNSYLVANIA AVENUE NW		PHAM, HOA Q		
WASHINGTO	N, DC 20004		ART UNIT	PAPER NUMBER
			2977	

DATE MAILED: 09/04/2003

Please find below and/or attached an Office communication concerning this application or proceeding.

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		Application No.	Applicant(s)				
Office Action Summary		09/899,383	CHALMERS ET AL.				
		Examiner	Art Unit				
		Hoa Q. Pham	2877				
Period f	The MAILING DATE of this communication apports or Reply	pears on the cover sheet with the	correspondence address				
THE - Extra after - If th - If N - Fail - Any	MORTENED STATUTORY PERIOD FOR REPL MAILING DATE OF THIS COMMUNICATION. ensions of time may be available under the provisions of 37 CFR 1.1 r SIX (6) MONTHS from the mailing date of this communication. e period for reply specified above is less than thirty (30) days, a repl o period for reply is specified above, the maximum statutory period ure to reply within the set or extended period for reply will, by statute reply received by the Office later than three months after the mailing the patent term adjustment. See 37 CFR 1.704(b).	136(a). In no event, however, may a reply be by within the statutory minimum of thirty (30) d will apply and will expire SIX (6) MONTHS fro a, cause the application to become ABANDOR	timely filed lays will be considered timely. om the mailing date of this communication. NED (35 U.S.C. § 133).				
Status	Possessive to communication(s) filed on 25	luly 2003					
1)⊠	_	nis action is non-final.					
2a)⊠	,		procedution as to the mosts is				
3)□	closed in accordance with the practice under	Ex parte Quayle, 1935 C.D. 11	, 453 O.G. 213.				
•	tion of Claims	n					
4)(\(\text{\tint{\text{\te}\text{\texi}\text{\text{\texit{\tex{\text{\text{\text{\text{\text{\texi}\text{\texit{\text{\ti	Claim(s) <u>1-65</u> is/are pending in the application 4a) Of the above claim(s) is/are withdra						
5 \	•	Will from consideration.					
•	Claim(s) is/are allowed.						
7)□	Claim(s) <u>1-65</u> is/are rejected. Claim(s) is/are objected to.						
	Claim(s) are subject to restriction and/o	or election requirement.					
•	tion Papers	1					
9)[The specification is objected to by the Examine	er.					
10)	The drawing(s) filed on is/are: a) acce	epted or b) objected to by the Ex	kaminer.				
	Applicant may not request that any objection to the	ne drawing(s) be held in abeyance.	See 37 CFR 1.85(a).				
11)	The proposed drawing correction filed on	_ is: a)□ approved b)□ disapp	proved by the Examiner.				
	If approved, corrected drawings are required in re	eply to this Office action.					
12)[The oath or declaration is objected to by the E	xaminer.					
Priority	under 35 U.S.C. §§ 119 and 120						
13)[Acknowledgment is made of a claim for foreig	n priority under 35 U.S.C. § 119	9(a)-(d) or (f).				
а) All b) Some * c) None of:						
	1. Certified copies of the priority documen	its have been received.					
	2. Certified copies of the priority documents have been received in Application No						
*	3. Copies of the certified copies of the pricapplication from the International Boundary See the attached detailed Office action for a list	ureau (PCT Rule 17.2(a)).					
	Acknowledgment is made of a claim for domes			n).			
, —	a) The translation of the foreign language processes the compact of the foreign language processes and the compact of the foreign language processes and the compact of the foreign language processes and the compact of the foreign language processes.	ovisional application has been r	received.				
Attachme	•	;					
1) No.	rice of References Cited (PTO-892) tice of Draftsperson's Patent Drawing Review (PTO-948) prmation Disclosure Statement(s) (PTO-1449) Paper No(s)	5) Notice of Inform	nary (PTO-413) Paper No(s) In al Patent Application (PTO-152)				

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DETAILED ACTION

Claim Rejections - 35 USC § 103

- 1. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 2. Claims 1-55, 58-61 and 64-65 are rejected under 35 U.S.C. 103(a) as being unpatentable over Ledger (5,436,725) in view of Cabib et al (5,856,871) and Finland reference (*ImSpector* imaging Spectrograph brochure including specifications, **Spectral Imaging Ltd**,) (of record).

Regarding claims 1, 7, 16-19, 21, 24, 27, 35-41, and 64-65; Ledger discloses a method and apparatus for measuring the thickness of a thin film on a pattern wafer in which the thickness of the thin film is determined on the basis of the combination between the low resolution imaging means and high resolution imaging means. In addition, Ledger teaches that it is well known in the art that the thickness of the thin film can be determined on the basis of either low resolution imaging means or high resolution imaging means (column 1, lines 32-44). Ledger does not explicitly teach that an imaging spectrometer for deriving a plurality of one-spatial-dimension spectral images. However, such a feature is known in the art as taught by Cabib et al and Finland reference. Cabib et al teaches that an imaging spectrometer or spectral imager using for resource mapping of the earth surface from airplanes and satellites could be used for film thickness mapping (column 2 lines 8-23). Furthermore, Finland reference

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teaches that imaging spectrometer is a one-spatial-dimension imaging spectrometer (figure in page 1). It would have been obvious to one having ordinary skill in the art at the time the invention was made to include in Ledger a high resolution imaging spectrometer, since Ledger suggests the use of a high resolution image means, Cabib et al teaches that an imaging spectrometer or spectral imager using for resource mapping of the earth surface from airplanes and satellites could be used for film thickness mapping and Finland reference teaches the use of an imaging spectrometer.

Regarding claims 2-3, 23, 25, it would have been obvious to one having ordinary skill in the art at the time the invention was made to provide resolution of 1 mm or better along the both first and second spatial dimensions. Thus, an accuracy of the measurement is obtained.

Regarding claims 4-5 and 15, the vacuum chuck in column 4, lines10-12 of Ledger is considered as translation mechanism.

Regarding claims 6, 10-14, 26, 30-34, 42-49, and 64-65, Ledger teaches that the thickness of the thin film is measured at one or more desired locations (column 1, lines 6-8; column 2, lines 50-62, column 4, lines 13-22).

Regarding claims 8-9, 28-29, see claim 5 of Ledger for comparison.

Regarding claims 20 and 22, using wireless or optical communication link is well known in the art. Thus, it would have been obvious to modify the system of Ledger by a wireless system.

Regarding claims 50-51, see figure 1 of Ledger for the reflected light perpendicular to the surface.

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Regarding claims 52-53, see figure 1 of Cabib et al.

Regarding claims 54-55, Ledger does not use polarized light.

Regarding claims 58-61, Ledger does not explicitly teach that the properties relate to metal leads. However, it would have been obvious to one having ordinary skill in the art at the time the invention was made to use the basis device of Ledger for detecting the properties of a substrate having metal leads because the device would function in the same manner.

3. Claims 56-57 and 62-63 are rejected under 35 U.S.C. 103(a) as being unpatentable over Ledger, Cabib et al and Finland reference as applied to claims 1-55, 58-61 above, and further in view of Tompkins et al (Spectroscopic Ellipsometry and Reflectometry).

Regarding claims 62-63, Ledger does not explicitly teach the use of a reflectometry such as an ellipsometry system. However, such a feature is known in the art, for example, taught by Tompkins et al (of record). Tompkins et al discloses a spectroscopic ellipsometry and reflectometry (described in page 18 of present specification) for measuring the thickness of a film layer. It would have been obvious to one having ordinary skill in the art at the time the invention was made to replace the system of Ledger by a reflectometry system or ellipsometry system for the same purpose of determining the thickness of a layer. The substitution for one another is generally recognized as being within the level of ordinary skill in the art.

Regarding claims 56-57, it is inherent that the polarized light is used in the ellipsometry system.

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Response to Arguments

4. Applicant's arguments filed 7/25/03 have been fully considered but they are not persuasive.

- a. Applicant's remarks, page 10, argue that the references do not teach the pattern film is inspected; however, this limitation is cited in the preamble. Therefore no patentable weight is given. In addition, Ledger teaches that thickness of a film layer on a pattern wafer is determined.
- b. Using a high resolution imaging imager is taught by Ledger as mentioned above.
 - c. The two step procedure are not cited in claims 1, 24, 40, and 41.
- d. With respect to claims 64 and 65, Ledger teaches the two step procedure as mentioned above.

In view of the foregoing, it is believe that the rejection of claims 1-65 under 35 U.S.C 103 is proper.

5. Applicant's amendment necessitated the new ground(s) of rejection presented in this Office action. Accordingly, **THIS ACTION IS MADE FINAL**. See MPEP § 706.07(a). Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not

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mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the date of this final action.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Hoa Q. Pham whose telephone number is (703) 308-4808. The examiner can normally be reached on 6:30 AM to 5 PM, Monday through Thursday.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Frank G. Font can be reached on (703) 308-4881. The fax phone number for the organization where this application or proceeding is assigned is (703) 872-9306.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is (703) 308-0956.

Hoa Q. Pham Primary Examiner Art Unit 2877

HP August 22, 2003